

Notice of References Cited

Application/Control No.

09/920,978

Applicant(s)/Patent Under
Reexamination
TRAPP, SHANE J.

Examiner

David S Blum

Art Unit

2813

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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
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	C	US-			
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Stanley Wolf SILICON PROCESSING FOR THE VSLI ERA VOL. 2 Lattice Press 1990 pages 52-54
	V	BELL LABS SCIENTISTS DEVELOP 193 nm SINGLE-LAYER PHOTORESIST Bell Labs News 4/1997
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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